REQUEST FOR RECONSIDERATION

The rejection of claim 7 under 25 U.S.C. § 102(e) as being anticipated by to U.S. Patent No. 6,896,591 to Chaneyalew et al. is respectfully traversed.

The reference does not disclose or suggest the polishing step in claimed invention, in which the aqueous dispersion comprises abrasive grains that include (A) simple particles comprising at least one selected from the group consisting of inorganic particles and organic particles; and (B) composite particles, in which the composite particles (B) are composed of inorganic organic composite particles obtained by integrally combining organic particles with inorganic particles.

The reference <u>Chaneyalew et al.</u> reference generally a chemical-mechanical polishing compositions containing mixed abrasives and their use to polish substrates. The reference also describes a method of polishing a substrate, in the which method comprises the steps of (i) providing a polishing composition, (ii) providing a substrate having a surface, and (iii) abrading at least a portion of the substrate surface with the polishing composition to polish the substrate. (Column 6, lines 12-24).

In particular, the polishing composition described in the reference comprises:

(i) an abrasive comprising (a) about 5 to about 45 wt. % of first abrasive particles having a Mohs' hardness of about 8 or more, (b) about 1 to about 45 wt. % of second abrasive particles having a three-dimensional structure comprising aggregates of smaller primary particles, and (c) about 10 to about 90 wt. % of third abrasive particles comprising silica, and (ii) a liquid carrier.

(Abstract and Column 2, lines 23-31). (Emphasis added). According to the reference, "[m]ost preferably, the **first abrasive particles** are α-alumina particles," "the **second abrasive particles** are <u>fumed alumina particles</u>," "[t]he **third abrasive particles** used in conjunction with the invention can comprise <u>any suitable silica</u>." (Column 3, lines 3-4, lines) 35-36, and lines 55-56; see also Examples A-F at column 8). (Emphasis added).

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In contrast, the composite particles of the claimed invention are "composed of the

inorganic organic composite particles," in which they are "obtained by integrally combining

organic particles with inorganic particles in the extent that these particles are not easily

separated." (Present specification at page 13, lines 3-7).

Thus, in view of the foregoing reasons, Applicants respectfully request the withdrawal

of the rejection under 35 U.S.C. § 102(e).

Applicants further submit that new claims 9-11 are novel and unobvious over the

references of record, since they depend, directly or indirectly, from the novel and unobvious

deodorant composition of amended claim 7.

The objection to claim 1 has been obviated by amendment.

Applicants submit that the application is now in condition for allowance. Early

notification of such allowance is earnestly solicited.

Respectfully submitted,

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